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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application of: SMALL, Robert J., et al.

Serial No.: 10/683,730

Art Unit: 2812

Filed: October 1, 2003

Examiner: Quoc Dinh HOANG

For: CHEMICAL MECHANICAL
POLISHING COMPOSITION
AND PROCESS

Attorney Docket No: 060937-0211
(formerly 8317-
211-999)

PETITION FOR EXTENSION OF TIME

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

Sir:

It is respectfully requested that the time for response to the Restriction Requirement dated March 24, 2004, be extended for a period of one (1) month from April 24, 2004 up to and including May 24, 2004.

The fee for this extension is **\$110.00**. Please charge the required fee to Morgan, Lewis & Bockius LLP Deposit Account No. 50-0310.

Date: May 24, 2004

Respectfully submitted,

Christopher G. Hayden (Reg. No. 44,750)

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